

# Chapter 2900: International Design Applications

- 2901 Basic Hague Agreement Principles
- 2902 Definitions
- 2903 Declarations under the Hague Agreement Made by the United States of America
- 2904 Who May File An International Design Application
- 2905 Where to File An International Design Application 2905.01-Filing Through the USPTO as an Office of Indirect Filing
- 2906 Filing Date Requirements
- 2907 International Registration and Date of the International Registration
- 2908 Filing Date in the United States
- 2909 Contents of the International Design Application 2909.01-Official Form for the Application for International Registration
  - 2909.02 Reproductions (Drawings) 2909.02(a)-Reproductions Submitted Through EFS-Web
  - 2909.03 Annexes
- 2910 International Design Application Fees
- 2911 Representation
- 2912 Correspondence in Respect of International Design Applications Filed With the USPTO as an Office of Indirect Filing
- 2913 Relief from Prescribed Time Limits
- 2914 Conversion of an International Design Application to a Design Application Under 35 U.S.C. Chapter 16
- 2915-2919 [Reserved]
- 2920 National Processing of International Design Applications Designating the United States
  - 2920.01 Inventorship
  - 2920.02 Applicant
  - 2920.03 Correspondence Address

2920.04 Elements of a Nonprovisional International Design Application

2920.04(a) Specification

2920.04(b) Reproductions (Drawings)

2920.04(c) Inventor's Oath or Declaration

2920.05 Examination

2920.05(a) Notification of Refusal

2920.05(b) One Independent and Distinct Design

2920.05(c) Considerations Under 35 U.S.C. 112

2920.05(d) Foreign Priority

2920.05(e) Benefit Claims Under 35 U.S.C. 386(c)

2920.05(f) Information Disclosure Statement in an International Design  
Application Designating the United States

2920.06 Allowance

2921-2929 [Reserved]

2930 Corrections and Other Changes in the International Register

2931-2939 [Reserved]

2940 Statement of Grant of Protection

2941-2949 [Reserved]

2950 Grant of Protection Only Upon Issuance of Patent; Term of Design Patent